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APPLICATION NO.	FILING DATE		FIRST NAMED INVENTOR Hui Wang	ACMR-001-02US	CONFIRMATION NO.	
09/837,902	04/18/2001					
20872	7590	07/29/2004		EXAMINER		
		RSTER LLP	LEADER, WILLIAM T			
425 MARKET STREET SAN FRANCISCO, CA 94105-2482				ART UNIT	PAPER NUMBER	
				1742	1742	

DATE MAILED: 07/29/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

MJ

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		Ap	pplication No.	Applicant(s)					
			9/837,902	WANG, HUI					
	Office Action Summary	Ex	aminer	Art Unit					
			lliam T. Leader	1742					
Period fe	The MAILING DATE of this commu or Reply	nication appears	s on the cover shee	t with the correspondence a	ddress				
THE - External control	MAILING DATE OF THIS COMMUN ensions of time may be available under the provision of SIX (6) MONTHS from the mailing date of this come e period for reply specified above is less than thirty to period for reply is specified above, the maximum sure to reply within the set or extended period for rep preply received by the Office later than three months are departed term adjustment. See 37 CFR 1.704(b).	NICATION. ns of 37 CFR 1.136(a). nmunication. (30) days, a reply with a statutory period will apply will, by statute, caus	In no event, however, ma n the statutory minimum of ply and will expire SIX (6) ! e the application to becom	y a reply be timely filed thirty (30) days will be considered tim MONTHS from the mailing date of this e ABANDONED (35 U.S.C. & 133)	ely. communication.				
Status	, , ,								
1)[\	Responsive to communication(s) fil	lad on 22 April 3	2004	•	•				
2a)☐	This action is FINAL .	2b)⊠ This acti							
/ _		•		latters prosecution as to th	na marite is				
٠/١ـــا	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Disposit	ion of Claims	•		,					
	Claim(s) <u>110-138</u> is/are pending in	the application.							
	4a) Of the above claim(s) <u>111-115 a</u>	and 120-138 is/a	are withdrawn from	consideration.					
·	Claim(s) is/are allowed.								
	Claim(s) <u>110 and 116-119</u> is/are rej	jected.							
7)	Claim(s) is/are objected to.								
8)[Claim(s) are subject to restri	iction and/or ele	ction requirement.						
Applicat	ion Papers								
9)[The specification is objected to by the	ne Examiner.							
10)	The drawing(s) filed on is/are	e: a) 🗌 accepted	d or b) Dobjected	to by the Examiner.					
	Applicant may not request that any object	ection to the draw	ing(s) be held in abe	yance. See 37 CFR 1.85(a).					
	Replacement drawing sheet(s) including	g the correction is	required if the drawi	ng(s) is objected to. See 37 C	FR 1.121(d).				
11)	The oath or declaration is objected t	to by the Examir	ner. Note the attach	ned Office Action or form P	TO-152.				
Priority ι	ınder 35 U.S.C. § 119								
	Acknowledgment is made of a claim All b) Some * c) None of:			. § 119(a)-(d) or (f).					
	1. Certified copies of the priority								
	2. Certified copies of the priority								
	3. Copies of the certified copies			en received in this Nationa	Stage				
* 5	application from the Internation See the attached detailed Office action		, ,,	at received					
	no the attached detailed office action	on to a list of the	e certified copies fi	ot received.					
Attachmen	, ,								
	e of References Cited (PTO-892)	770 010	4) Interview	w Summary (PTO-413)					
2) 🔲 Notic 3) 🔯 Inforr	e of Draftsperson's Patent Drawing Review (F nation Disclosure Statement(s) (PTO-1449 or	PTO-948) r PTO/SB/08\		lo(s)/Mail Date of Informal Patent Application (PT	O-152)				
	r No(s)/Mail Date <u>4-18-01;3-13-03</u> .		6) 🔲 Other: _		,				

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DETAILED ACTION

1. Receipt of the papers filed on April 23, 2004,is acknowledged. Applicant has elected species 1, claims 110 and 116-119 without traverse. Claims 111-115 and 120-138 are withdrawn from consideration.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 110 and 116-119 are rejected under 35 U.S.C. 102(b) as being anticipated by Kubo et al (5,326,45).
- 4. The Kubo et al patent is directed to a process employing electroplating.

 Copper is deposited onto drum 11 which serves as the substrate. The drum is rotated (column 6, lines 46-50). Electrolyte is flowed directly along the surface of the drum. See figure 1. The substrate may be divided into portions both widthwise and lengthwise. See dimensions "m" and "k" in figure 5. In one interpretation a first portion may be taken as being at one position along the width, and a second portion at a different position along the width. Kubo et al teach obtaining a uniform

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thickness by plating the film to a desired thickness on the first portion of the substrate and on the second portion as recited in claim 1. See the abstract. Thus, all steps recited in claim 110 are taught by Kubo et al.

- 5. Kubo et al disclose that current is supplied to the different portions along the width (dimension "k") of the substrate by a series of sub-anodes 14 which are individually controlled (column 6, lines 19-25). Thus plating current is applied to the first and second portions separately as recited in claim 116. Alternatively, the different portions may be considered to be spaced along the length (dimension "m") of the substrate. Then, plating current is separately supplied to a first portion by main anodes 13 and to the second portion by sub-anodes 14.
- 6. Claims 117 and 118 include the term "plating current". This term is considered to refer to electric current which causes electroplating to occur. By causing electroplating to occur, the application of a "plating current" clearly prevents deplating. Claim 117 requires the application of plating current to the first portion after the film reaches the desired thickness on the first portion while applying plating current to the second portion. Kubo et al teaches that the main anodes 13 produce about 90-98% of the total thickness of the foil (column 8, lines 23-24). The substrate opposed by the last section of main anodes 13 is considered to be the first portion. As this portion is rotated past the end of the main anode, the desired thickness of 90-98% is obtained. This first portion then rotates toward sub-

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anodes 14 where plating current is applied by the sub-anodes. At the same time, a new part of the substrate, which may be considered a second portion, is rotated into opposition with the main anodes, and plating current is applied to this second portion. All limitations of claim 117 are taught by Kubo et al. Kubo et al likewise meets the limitations of claim 118.

- 7. Claim 119 further recites moving the first portion of the substrate out of the electrolyte while applying plating current to the second portion of the substrate. As shown in figure 5 of Kubo et al, the drum carrying the first portion (as taken in paragraph 6 above) is rotated out of the electrolyte while current is still being applied to the second portion of the substrate.
- 8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The Luce et al patent (4,898,647) discloses a process in which electroplating current is separately applied to first and second portions of a rotating substrate while electrolyte is flowed onto the surface of the substrate.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to William T. Leader whose telephone number is 571-272-1245. The examiner can normally be reached on Mondays-Thursdays and alternate Fridays, 7:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Roy King can be reached on 571-272-1244. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

William Leader July 21, 2004

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